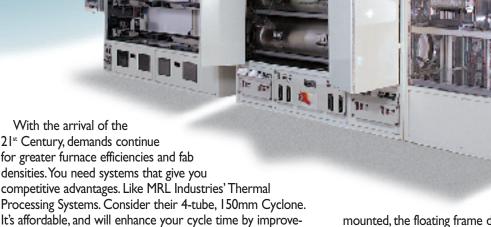
MRL'S Horizontal Thermal Processing Systems

## Low cost of ownership.

Ready for 21" Century Performance!



**Higher Productivity and Enhanced Thermal Technology** 

ments in yield rates, throughput and reliability-resulting in

■ 30"/40" flat zones for 150–200mm wafers and 24"/30" flat zones for 300mm wafers. ■ Features MRL's proven and precise heating elements, an individual exhaust manifold for tube level control and a fully integrated PC-based DDC process controller.

## **User-Friendly and Safe**

low overall cost of ownership.

■ Provides for easy and safe operation, spare parts access and maintenance. ■ Elements are mounted on slides for easy removal while the hinged/bi-fold doors and panels permit quick service access. ■ Control components are drawer-

mounted, the floating frame design provides improved weight distribution. Source cabinet components are slide-mounted for access during rear tube pull.

## MRL... Heating Up the 21st Century

■ MRL provides quality vertical and horizontal semiconductor furnace systems and heating elements. ■ Serves specific and standard customer process requirements.

